

(19) World Intellectual Property Organization  
International Bureau



(43) International Publication Date  
6 October 2005 (06.10.2005)

PCT

(10) International Publication Number  
WO 2005/092823 A2

(51) International Patent Classification<sup>7</sup>: C07C 17/00 (81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SM, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.

(21) International Application Number: PCT/JP2005/006521

(22) International Filing Date: 28 March 2005 (28.03.2005)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data: 2004-095012 29 March 2004 (29.03.2004) JP  
60/559,428 6 April 2004 (06.04.2004) US

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(84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

**Published:**

— without international search report and to be republished upon receipt of that report

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

WO 2005/092823 A2

(54) Title: PROCESS FOR PRODUCTION OF 1,1,1,2-TETRAFLUOROETHANE AND/OR PENTAFLUOROETHANE AND APPLICATIONS OF THE SAME

(57) Abstract: A process for producing high purity 1,1,1,2-tetrafluoroethane and/or pentafluoroethane by the step of purifying a crude product obtained by reacting trichloroethylene and/or tetrachloroethylene with hydrogen fluoride comprised of a main product including 1,1,1,2-tetrafluoroethane and/or pentafluoroethane, hydrogen fluoride as an azeotropic component with the main product, and impurity ingredients including at least an unsaturated compound, wherein said purifying step includes a step of bringing a mixture obtained by newly adding hydrogen fluoride into said crude product into contact with a fluorination catalyst in the vapor phase to reducing the content of the unsaturated compound contained in said crude product and a distillation step.